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Journal of Organometallic Chemistry 685 (2003) 168-176

Journal ofOrgano metallic Chemistry

www.elsevier.com/locate/jorganchem

Disilagermirenes: heavy cyclopropenes of Si and Ge atoms

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Received 21 December 2002; accepted 3 March 2003

Dedicated to the 50th Anniversary of Polysilane Chemistry in 2003, and the pioneering work of Professor Makoto Kumada to this field and his outstanding contribution to silicon chemistry

Abstract

Tetrakis[di-*tert*-butyl(methyl)silyl]-1-disilagermirene (**3**) was prepared by the reaction of 2,2,2-tribromo-1,1-di-*tert*-butyl-1methyldisilane and dichlorobis[di-*tert*-butyl(methyl)silyl]germane with sodium in toluene. The molecular structure of **3** was established by X-ray crystallography, which showed a *trans*-bent configuration around the Si=Si double bond with a bond length of 2.146(1) Å. Thermal and photochemical isomerization of **3** to tetrakis[di-*tert*-butyl(methyl)silyl]-2-disilagermirene (**4**) is also reported, as well as the reactions of **3** with MeI, PhCH₂OH, and PhCOCH₃.

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Keywords: Cycloaddition; Cyclotrimetallene; Disilene; Germanium; Germasilene; Heavy cyclopropene; Silicon; Small ring; X-ray crystallographic analysis

1. Introduction

Cyclopropene, the smallest unsaturated ring system, together with its derivatives, represents one of the most important classes of organic compounds because of its enhanced reactivity caused by the large ring strain [1]. Very recently, it was demonstrated that the heavy neighbors of carbon in Group 14 (Si, Ge, Sn) are also capable of forming such unsaturated three-membered ring systems [2]. Despite the much greater difficulties in the preparation of such compounds compared with their carbon analogue (cyclopropene), they are becoming increasingly available, constituting a new highly promising and quickly developing class of organometallic compounds: heavy cyclopropenes. Such compounds tend to occupy a rather important position in the chemistry of heavier Group 14 elements, as the high reactivity of heavy cyclopropenes is much more pronounced than that of cyclopropene, because of the extreme reactivity of the endocyclic metal-metal double bond and the weakness of the endocyclic metal-metal single bonds [2].

Despite such great interest from the structural and synthetic viewpoints, the story of heavy cyclopropenes is very short, being only 8 years old: the first report on the germanium version, cyclotrigermenes, only appeared in 1995 (Sekiguchi et al.) [3]. After that report there was a period of extensive development of the chemistry of heavy cyclopropenes with an increase in the number of their representatives. Thus, the first silicon analogues, cyclotrisilenes, were synthesized in 1999 by the experimental efforts of two research groups—Kira et al. [4] and Sekiguchi et al. [5]. In the same year, the first and still the only example of a tin representative, cyclotristannene, was reported by Wiberg et al. [6], and finally, we have recently synthesized the first heavy cyclopropenes containing two different heavier Group 14 elements-isomeric 1- and 2-disilagermirenes, consisting of one germanium and two silicon atoms [7] and studied their reactivity [8]. In this paper we present the

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⁰⁰²²⁻³²⁸X/03/\$ - see front matter \odot 2003 Elsevier B.V. All rights reserved. doi:10.1016/S0022-328X(03)00651-X

full description of their synthesis, structural peculiarities and some new aspects of their chemical reactivity.

2. Results and discussion

The synthesis of the first three-membered unsaturated ring compound consisting of different heavier Group 14 elements required the preliminary preparation of the two corresponding precursors: 1,1,1-tribromo-2,2-di-tert-butyl-2-methyldisilane (1) (silicon part) and dichlorobis[di-*tert*-butyl(methyl)silyl]germane (2) (germanium part) (Scheme 1). The silicon part, compound 1, was prepared starting from SiF₄, which was reacted with ^tBuLi to produce ^tBu₂SiF₂ in 83% yield. The last compound was then methylated with MeLi to form ^tBu₂MeSiF (80% yield), which was in turn treated with Ph₃SiLi to give ^tBu₂MeSiSiPh₃ in 83% yield. Finally, the disilane ^tBu₂MeSiSiPh₃ was subjected to a dephenylation-bromination reaction with gaseous HBr in the presence of AlBr₃ catalyst to form the final precursor, ^tBu₂MeSiSiBr₃ (1), in 92% yield (Scheme 1). The germanium part, compound 2, was synthesized starting from MeHSiCl₂ which was reacted with ^tBuLi in pentane to form ^tBu₂MeSiH in 83% yield. This hydrosilane was subsequently brominated with Br2 in CH2Cl2 to form the corresponding bromide ^tBu₂MeSiBr (94% yield), which was then reacted with $(p-tolyl)_2$ GeCl₂ and Li in THF to form $(p-tolyl)_2$ Ge(SiMe^tBu₂)₂ in 62% yield. In the final step, the last compound was treated with gaseous HCl in the presence of catalytic AlCl₃ to form the second precursor, (^tBu₂MeSi)₂GeCl₂ (2), almost quantitatively (Scheme 1).

The final Würtz-type coupling reaction of precursors 1 and 2 with metallic sodium was carried out in toluene at room temperature. A dark red color quickly devel-

MeLi

Preparation of Si-Part:

⁴BuLi

oped, the reaction being monitored by GC, which showed the disappearance of starting material 1 after 7–8 h. At this time the reaction mixture was filtered to remove excess sodium and inorganic salts, and the filtrate was evaporated in vacuum. The residue was recrystallized from hexane in a refrigerator at -30 °C to form the target tetrakis[di-*tert*-butyl(methyl)silyl]-1-disilagermirene (3) as large hexagonal-shaped ruby crystals in 37% yield (Scheme 2). This compound is highly sensitive to atmospheric oxygen and moisture, being quickly decomposed in air even in the solid state.

All NMR spectra of **3** were in complete accord with its symmetrical structure: two sets of signals for both methyl and *tert*-butyl group protons in the ¹H-NMR spectrum, and three resonances in the ²⁹Si-NMR spectrum, of which two belong to silyl substituents (18.7 and 25.6 ppm) and the most deshielded one (107.8 ppm) was attributed to sp²-Si atoms. The mass-spectrum of **3** gave the parent ion peak at m/z = 758, together with a strong peak at 601, which corresponds to the elimination of one silyl substituent and formation of the cyclopropenylium ion in the gas phase. The UV



$$SiF_{4} \xrightarrow{pentane} {}^{Bu_{2}SiF_{2}} \xrightarrow{Et_{2}O} {}^{Bu_{2}MeSiF} \xrightarrow{J} {}^{Bu_{2}MeSiSiPh_{3}}$$

$$\xrightarrow{HBr / AlBr_{3}} {}^{Bu_{2}MeSiSiBr_{3}} \xrightarrow{I}$$

$$Preparation of Ge-Part:$$

$$MeHSiCl_{2} \xrightarrow{I'BuLi} {}^{BuLi} {}^{Bu_{2}MeSiH} \xrightarrow{Br_{2}} {}^{I}Bu_{2}MeSiBr \xrightarrow{(p-tolyl)_{2}GeCl_{2}/Li} {}^{I'Bu_{2}MeSi)_{2}Ge(p-tolyl)_{2}}$$

$$\xrightarrow{HCl / AlCl_{3}} {}^{(Bu_{2}MeSi)_{2}GeCl_{2}} 2$$

$$Scheme 1.$$

Ph₃SiLi

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Fig. 1. Crystal designer view of 3. Selected bond lengths (Å): Si(1)–Si(2) = 2.146(1), Ge(1)–Si(1) = 2.415(1), Ge(1)–Si(2) = 2.420(1), Ge(1)–Si(5) = 2.435(1), Ge(1)–Si(6) = 2.432(1), Si(1)–Si(3) = 2.361(1), Si(2)–Si(4) = 2.367 (1). Selected bond angles (°): Ge(1)–Si(1)–Si(2) = 63.76(3), Ge(1)–Si(2)–Si(1) = 63.53(3), Si(1)–Ge(1)–Si(2) = 52.71(3), Si(5)–Ge(1)–Si(6) = 123.33(3). Selected torsion angle (°): Si(3)–Si(1)–Si(2)–Si(4) 37.0(2).

spectrum of 3 showed a long wavelength absorption band at 469 nm, corresponding to the $\pi - \pi^*$ electronic transition due to the Si=Si double bond. The crystal structure of 3 was determined by X-ray diffraction analysis, which showed a triangular skeleton composed of one sp³-Ge atom and two sp²-Si atoms (Fig. 1). The endocyclic Si-Ge bond lengths of 2.415 and 2.420 Å are in the normal range for such bonds (2.384-2.457 Å) [9], and they are intermediate between the typical Si-Si and Ge-Ge bond lengths. The most important feature is the Si=Si double bond distance of 2.146(1) Å, which is one of the shortest Si=Si bond lengths reported thus far (2.138–2.289 Å) [10]. The geometry of substituents at the Si=Si double bond has a trans-bent character with the bending angle of 37° . This may be the result of the eclipsed conformation of the two silvl substituents on the sp²-Si atoms, which can repulsively interact with the silvl substituents on the Ge atom, causing the highly pronounced trans bending geometry.

As is expected, and similar to the case of other disilenes, the Si=Si double bond in **3** is highly reactive, despite the bulky environment around it. The most significant result is the allylic-type rearrangement of **3** to form an isomeric tetrakis[di-*tert*-butyl(methyl)sily]]-2-disilagermirene (**4**), which no longer has a Si=Si double bond, but instead has a Si=Ge double bond. This isomerization may proceed either photochemically or thermally (Scheme 2). Thus, photolysis of the solution of **3** in C₆D₆ with a high-pressure Hg lamp with light of wavelength longer than 300 nm produced **4** nearly

quantitatively, and this isomerization could be easily monitored by either ¹H-NMR or UV spectroscopy, which showed the disappearance of starting material 3 and clean formation of 4 in 6-8 h. Alternatively, 3 can be isomerized quantitatively under thermal conditions: heating a solution of **3** in mesitylene at 120 °C for 12 h caused the complete conversion of 3 to 4. However, the best way to achieve isomerization is the thermolysis of 3 without solvent in a sealed evacuated tube at 215 °C, which is slightly above the melting point of 3 (205-207 °C). Surprisingly, under such drastic conditions isomeric 2-disilagermirene 4 was formed almost quantitatively without formation of any side or decomposition products. Nevertheless, both isomerization conditions (either thermal or photochemical) gave an equilibrium mixture of 4 (~98–99%) and 3 (~1–2%), and from this ratio it was estimated that 4 is more stable than 3 by \sim 3 kcal mol⁻¹. This corresponds well to the results of theoretical calculations on the model H₃Si-substituted disilagermirenes at the B3LYP/DZd level [11], which also showed that 2-disilagermirene is more stable than 1disilagermirene by ~ 2.3 kcal mol⁻¹.

The NMR spectral data of **4** are more complicated due to its unsymmetrical structure. In the ¹H-NMR spectrum of **4** there are three distinct resonances for the methyl groups and four for the *tert*-butyl groups, whereas in the ¹³C-NMR spectrum there are three sets of signals for both the methyl and *tert*-butyl groups. The ²⁹Si-NMR spectrum showed a total of five resonances: three belong to silyl substituents, and the other two to skeletal Si atoms: -120.1 ppm for the sp³-Si atom and +100.7 ppm for the sp²-Si atom.

The crystal structure of **4** was determined by X-ray diffraction analysis. This showed the expected cyclopropene-type skeleton consisting of one sp³-hybridized Si atom and two sp² hybridized Si and Ge atoms, which form the Si=Ge double bond. Unfortunately, owing to the disorder problem between Si and Ge atoms (nearly 50:50% probability for each position), it was not possible to determine the Si=Ge double bond length, although the geometry of the Si=Ge double bond was found to be *trans*-bent with a bending angle of 40.3°. Calculations on the model H₃Si-substituted 2-disilagermirene at the B3LYP/DZd level gave the length of the Si=Ge double bond as 2.178 Å, almost the same as that of 2.184 Å for H₂Si=GeH₂ previously reported by Grev et al. [12].

We have investigated other examples of the reactivity of **3**, first of all 1,2-addition and cycloaddition reactions [8]. 1,2-Addition of a variety of reagents to Si=Si double bonds is well documented [13]. Our case was not exceptional, and 1-disilagermirene **3** easily undergoes addition across the Si=Si double bond, despite the presence of very bulky substituents. This method gave us the unique opportunity for easy and fast access to a number of saturated three-membered ring compounds of different heavier Group 14 elements. In this paper, we describe the new reactions of 1-disilagermirene 3 with methyl iodide and benzyl alcohol. Reaction of 3 with MeI in benzene solution proceeds very quickly to give the corresponding 1,2-adduct, trans-1,2,3,3-tetrakis[di*tert*-butyl(methyl)silyl]-1-iodo-2-methyldisilagermirane (5), isolated quantitatively as yellow crystals (Scheme 3). The crystal structure analysis of 5 showed a disilagermirane skeleton with the anticipated *trans* arrangement of methyl group and iodine atom (Fig. 2). The reaction of benzyl alcohol with 1-disilagermirene 3 proceeded more slowly and was complete after stirring overnight at room temperature in benzene solution (Scheme 3). The

structure of the single product 6, trans-1-benzyloxy-

1,2,3,3-tetrakis[di-tert-butyl(methyl)silyl]disilagermirane, isolated as yellow crystals in 70% yield, was determined by NMR and X-ray diffraction analysis, which showed that in this case the reaction also proceeded stereospecifically as trans addition across the Si=Si double bond. It is worth mentioning here that earlier mechanistic studies of the reaction of transient disilenes with simple alcohols established the syn addition pathway [14]. In the present case the predominant trans addition of PhCH₂OH to the Si=Si bond should be definitely ascribed to steric reasons, which favor the formation of the less sterically hindered trans isomer [15].

Cycloaddition of unsaturated compounds and 1disilagermirene 3 provides effective access to bicyclic fused compounds having a disilagermirane fragment. We have previously reported reactions of 3 with carbonyl compounds (such as PhCHO), which proceed as the expected [2+2] cycloadditions stereospecifically to form bicyclic compounds as a single stereoisomer [16]. We have observed another reaction mode in the case of enolizable carbonyl compounds having α-hydrogen atoms [17]. Thus, acetophenone smoothly reacts with 3 in benzene solution at room temperature to form

stereospecifically the cis-1,2-adduct 7, cis-1,2,3,3-tetrakis[di-tert-butyl(methyl)silyl]-1-(1-phenylvinyloxy)disilagermirane, which was identified by NMR spectroscopy (Scheme 4). This product is the result of 1,2-addition of 1-phenylvinyl alcohol (the enol form of acetophenone) to the Si=Si double bond. As can be seen, such cis addition is consistent with the aforementioned syn addition of simple alcohols to transient disilenes [14]. Nevertheless, the cis isomer is not stable under the reaction conditions, and gradually isomerized in a benzene solution during 2 days at room temperature

Fig. 2. Crystal designer view of 5. Selected bond lengths (Å): Si(1)-

2.4762(10), Si(1)-Si(5) = 2.4239(14), Si(2)-Si(6) = 2.4220(14), Ge(1)-Si(6) = 2.4220(14), Ge(1

Ge(1) - Si(1) = 2.4749(10),



Si(2) = 2.3696(13),







Ge(1) - Si(2) =



Scheme 4.

The reason for such an isomerization seems to be a decrease in steric hindrance on going from *cis* to *trans* isomers. As can be seen, similar to the case of the reaction of **3** with benzyl alcohol, the final formation of the *trans* isomer is always favorable. The structure of *trans*-**7** was determined by means of all spectral data and X-ray analysis (Fig. 3), which showed the disilagermirane skeleton with the *trans* arrangement of H and H₂C=C(Ph)O substituents. Thus, the reaction of **3** with acetophenone represents a new reaction mode for the interaction of disilenes with carbonyl compounds: an 'ene'-type reaction resulting in the formation of the corresponding enol ether products instead of the only previously known and commonly recognized [2+2] cycloaddition pathway [13a-d].

3. Experimental

3.1. General procedures

All experiments were performed using high-vacuum line techniques or in an argon atmosphere of MBRAUN



Fig. 3. Crystal designer view of *trans*-7. Selected bond lengths (Å): Si(1)–Si(2) = 2.3383(6), Ge(1)–Si(1) = 2.4901(5), Ge(1)–Si(2) = 2.4524(5), Ge(1)–Si(3) = 2.4612(5), Ge(1)–Si(4) = 2.4586(5), Si(1)–Si(5) = 2.3978(6), Si(2)–Si(6) = 2.3944(6), Si(1)–O(1) = 1.6929(12). Selected bond angles (°): Si(2)–Ge(1)–Si(1) = 56.467(14), Si(2)–Si(1)–Ge(1) = 60.951(15), Si(1)–Si(2)–Ge(1) = 62.582(16).

MB 150B-G glove-box. All solvents were predried over sodium benzophenone ketyl and finally dried and degassed over potassium mirror in vacuum prior to use. NMR spectra were recorded on a Bruker AC-300FT NMR spectrometer (¹H-NMR at 300.13 MHz; ¹³C-NMR at 75.47 MHz; ²⁹Si-NMR at 59.63 MHz). GC-MS spectra were obtained using Shimadzu GCMS-QP5000 instrument and direct mass-spectra were obtained on JEOL JMS SX-102 instrument. UV-spectra were recorded on a Shimadzu UV-3150 UV-Vis spectrophotometer in hexane. Elemental analysis was performed at the Analytical Center of Tohoku University (Sendai, Japan).

 $(p-\text{Tolyl})_2\text{GeCl}_2$ was synthesized by the reaction of (p-tolyl)MgCl (prepared from $p-\text{CH}_3\text{C}_6\text{H}_4\text{Cl}$ and Mg in THF) and GeCl₄ in THF by the slightly modified experimental procedure [18]. ^{*t*}Bu₂SiF₂ was prepared by the reaction of SiF₄ with ^{*t*}BuLi in pentane according to Ref. [19], ^{*t*}Bu₂MeSiF by the methylation of ^{*t*}Bu₂SiF₂ with MeLi in Et₂O, ^{*t*}Bu₂MeSiH by the reaction of MeSiHCl₂ with ^{*t*}BuLi according to Ref. [20], and ^{*t*}Bu₂MeSiBr by the bromination of ^{*t*}Bu₂MeSiH with Br₂ in CH₂Cl₂ according to Ref. [21].

3.2. Synthesis of ^t Bu₂MeSiSiPh₃

A solution of Ph₃SiCl (40 g, 0.13 mol) in THF (80 ml) was slowly added at room temperature to a suspension of Li (9.5 g, 1.36 mol) in THF (240 ml) and reaction mixture was stirred overnight at room temperature. The resulting Ph₃SiLi was added dropwise to the solution of ^{*t*}Bu₂SiMeF (24 g, 0.14 mol) in THF (150 ml). The reaction was complete in 2 days refluxing and after usual work-up, Kugelrohr distillation gave 47 g (83%) of ^{*t*}Bu₂MeSiSiPh₃. B.p. 170–175 °C/0.2 mmHg; ¹H-NMR (C₆D₆) δ 0.44 (s, 3H, Me), 1.00 (s, 18H, ^{*t*}Bu), 7.14–7.16 and 7.77–7.80 (m, 15H, Ph); ¹³C-NMR (C₆D₆) δ –4.7, 21.6, 30.2, 128.1, 129.1, 137.3, 137.6; ²⁹Si-NMR (C₆D₆) δ –20.1, 1.2; GC–MS (*m*/*z*) 416 [M⁺], 359 (M⁺ – ^{*t*}Bu).

3.3. Synthesis of ^t $Bu_2MeSiSiBr_3$ (1)

Gaseous HBr was slowly bubbled at room temperature into the solution of ${}^{t}Bu_{2}MeSiSiPh_{3}$ (9.5 g, 22.9 mmol) in benzene (40 ml) containing catalytic amount of AlBr₃. After the reaction was complete (2 h), the solvent was evaporated and the residue was distilled by Kugelrohr distillation to give 8.9 g (92%) of ${}^{t}Bu_{2}MeSi-SiBr_{3}$ (1) as colorless solids. B.p. 80–110 °C/0.2 mmHg; ¹H-NMR (C₆D₆) δ 0.11 (s, 3H, Me), 1.06 (s, 18H, ${}^{t}Bu$); ¹³C-NMR (C₆D₆) δ – 8.2, 22.0, 29.3; ²⁹Si-NMR (C₆D₆) δ – 7.5, 10.3; GC–MS (*m*/*z*): 371 (M⁺ – {}^{t}Bu).

3.4. Synthesis of $({}^{t}Bu_{2}MeSi)_{2}Ge(p-tolyl)_{2}$

A mixture of ^tBu₂SiMeBr (3.02 g, 12.7 mmol) and (ptolyl)₂GeCl₂ (1.4 g, 4.3 mmol) in THF (15 ml) was slowly added at -10 °C to a suspension of Li (0.18 g, 25.7 mmol) in THF (50 ml). After stirring overnight at room temperature an additional amount of ^tBu₂SiMeBr (2.03 g, 8.6 mmol) in THF (7 ml) was added and the reaction mixture was refluxed for 1 day. After usual work-up, Kugelrohr distillation gave 1.52 g (62%) of (^tBu₂MeSi)₂Ge(*p*-tolyl)₂ as a colorless glass solidifying upon standing. B.p. 200-220 °C/0.2 mmHg, m.p. 129-131 °C; ¹H-NMR (C_6D_6) δ 0.60 (s, 6H, Me), 1.01 (s, 36H, ^tBu), 2.11 (s, 6H, $Me - C_6H_4$), 7.06 (d, J = 7.9 Hz, 4H, H_{arom}) and 7.99 (d, J = 7.9 Hz, 4H, H_{arom}); ¹³C-NMR (C_6D_6) δ -2.4, 21.4, 23.7, 30.7, 128.8, 137.4, 137.9, 138.4; ²⁹Si-NMR (C₆D₆) δ 14.5; MS (*m*/*z*): 413 $(M^+ -SiMe^t Bu_2).$

3.5. Synthesis of $({}^{t}Bu_{2}MeSi)_{2}GeCl_{2}$ (2)

Gaseous HCl was bubbled into a solution of $({}^{t}Bu_{2}-MeSi)_{2}Ge(p-tolyl)_{2}$ (0.5 g, 0.88 mmol) in benzene (10 ml), containing catalytic amount of AlCl₃, at room temperature. In 2.5 h the reaction was complete. Benzene was evaporated and the residue was extracted with dry hexane and filtered through Celite. After evaporation of filtrate practically pure product (${}^{t}Bu_{2}-MeSi)_{2}GeCl_{2}$ (2) was obtained in nearly quantitative yield. ¹H-NMR (C₆D₆) δ 0.31 (s, 6H, Me), 1.17 (s, 36H, ${}^{t}Bu$); ¹³C-NMR (C₆D₆) δ -6.1, 23.3, 29.7; ²⁹Si-NMR (C₆D₆) δ 26.0. MS (*m*/*z*): 458 [M⁺], 423 (M⁺ –Cl), 266 [(${}^{t}Bu_{2}MeSi$)GeCl].

3.6. Synthesis of 1,2,3,3-tetrakis[di-tertbutyl(methyl)silyl]-1-disilagermirene (3)

A mixture of ^{*t*}Bu₂MeSiSiBr₃ (7.85 g, 18.5 mmol) and (^{*t*}Bu₂MeSi)₂GeCl₂ (3.90 g, 8.5 mmol) in dry toluene (50 ml) was slowly added dropwise to a finely cutted pieces of sodium (4.3 g, 187 mmol) in dry toluene (50 ml) at room temperature. During the addition the exothermic reaction took place and the reaction mixture became dark-red. The reaction progress was monitored by GC-analysis, which showed disappearance of the starting ^{*t*}Bu₂MeSiSiBr₃ in 7 h stirring at room temperature. At that time the reaction was stopped and the reaction mixture was filtered off from the excess of sodium and inorganic salts through Celite. After evaporation of

solvent in vacuum the residue was recrystallized from hexane at -30 °C to give **3** as dark-ruby hexagonalshaped crystals (2.36 g, 37% yield). M.p. 205–207 °C; ¹H-NMR (C₆D₆) δ 0.46 (s, 6H, Me), 0.49 (s, 6H, Me), 1.22 (s, 36H, ^{*t*}Bu), 1.28 (s, 36H, ^{*t*}Bu); ¹³C-NMR (C₆D₆) δ -4.5, -2.2, 22.2, 23.6, 30.0, 31.0; ²⁹Si-NMR (C₆D₆) δ 18.7, 25.6, 107.8 (Si=Si); MS (*m*/*z*) 758 (M⁺, 0.1), 701 (M⁺ -^{*t*}Bu, 0.05), 601 (M⁺ -SiMe^{*t*}Bu₂, 2.6), 73 (100); UV (hexane) λ_{max} nm⁻¹ (ε) 230 (33 400), 259 (18 200), 308 (6300), 469 (1900). Anal. Found: C, 57.42; H, 10.75. Calc. for C₃₆H₈₄GeSi₆: C, 57.03; H, 11.17%.

3.7. Synthesis of 1,1,2,3-tetrakis[di-tertbutyl(methyl)silyl]-2-disilagermirene (4)

1-Disilagermirene **3** (50 mg, 0.07 mmol) was heated at 215 °C for 30 min in a sealed evacuated tube to form quantitatively 2-disilagermirene **4** as a pure compound. M.p. 194–196 °C; ¹H-NMR (C₆D₆) δ 0.43 (s, 6H, 2Me), 0.48 (s, 3H, Me), 0.53 (s, 3H, Me), 1.20 (s, 18H, ^{*t*}Bu), 1.22 (s, 18H, ^{*t*}Bu), 1.29 (s, 18H, ^{*t*}Bu), 1.30 (s, 18H, ^{*t*}Bu); ¹³C-NMR (C₆D₆) δ –4.6, –3.9, –2.2, 22.2, 22.8, 23.4, 29.9, 30.0, 31.3; ²⁹Si-NMR (C₆D₆) δ –120.1, 6.9, 27.8, 39.5, 100.7; MS (*m*/*z*) 758 (M⁺, 3), 701 (M⁺ –^{*t*}Bu, 1.5), 601 (M⁺ –SiMe^{*t*}Bu₂, 32), 73 (100); UV (hexane) λ_{max} nm⁻¹ (ε) 235 (58 100), 263 (27 000), 301 (11 600), 395 (1600), 467 (4200). Anal. Found: C, 56.53; H, 10.84. Calc. for C₃₆H₈₄GeSi₆: C, 57.03; H, 11.17%.

3.8. Reaction of 1,2,3,3-tetrakis[di-tertbutyl(methyl)silyl]-1-disilagermirene (3) with methyl iodide

Dry methyl iodide (0.2 ml, 50-fold excess) was vacuum transferred to a solution of 3 (48 mg, 0.06 mmol) in dry deuterobenzene (0.5 ml) in NMR tube, and then NMR tube was sealed under vacuum. The reaction progress was monitored by NMR spectroscopy, which showed that the reaction was complete in 1 h at room temperature to form a single product 5. This product was quantitatively isolated as bright-yellow crystals after evaporation of solvent and excess methyl iodide. M.p. 189–191 °C; ¹H-NMR (C₆D₆) δ 0.29 (s, 3H, Me), 0.34 (s, 3H, Me), 0.47 (s, 3H, Me), 0.75 (s, 3H, Me), 0.92 (s, 3H, Me), 1.21 (s, 18H, 2^tBu), 1.25 (s, 9H, ^tBu), 1.27 (s, 9H, ^tBu), 1.32 (s, 9H, ^tBu), 1.34 (s, 9H, ^tBu), 1.37 (s, 9H, ^tBu), 1.40 (s, 9H, ^tBu); ¹³C-NMR $(C_6D_6) \delta = -2.8, -2.0, 3.1, 3.2, 5.8, 23.1, 23.2, 23.36,$ 23.44, 23.7, 23.9, 24.0, 24.3, 30.6, 30.76, 30.83, 30.9, 31.1, 31.3, 31.5, 32.5; ²⁹Si-NMR (C₆D₆) δ -92.2, -80.3, 13.7, 16.3, 32.9, 35.9.

3.9. Reaction of 1,2,3,3-tetrakis[di-tertbutyl(methyl)silyl]-1-disilagermirene (3) with benzyl alcohol

Dry benzyl alcohol (9 mg, 0.08 mmol) and 3 (56 mg, 0.07 mmol) were placed in a glove-box to the glass tube with a magnetic stirring bar, then dry deuterobenzene (0.6 ml) was vacuum-transferred into this tube and tube was sealed under vacuum. After 1 day stirring at room temperature the reaction was complete to form nearly quantitatively one product 6. This product was isolated after evaporation of solvent by the recrystallization from hexane as yellow crystals (45 mg, 70%). M.p. 79–81 °C; ¹H-NMR (C₆D₆) δ 0.31 (s, 3H, Me), 0.33 (s, 3H, Me), 0.35 (s, 3H, Me), 0.46 (s, 3H, Me), 1.20 (s, 9H, ^tBu), 1.24 (s, 9H, ^tBu), 1.27 (s, 18H, 2^tBu), 1.28 (s, 18H, 2^tBu), 1.30 (s, 9H, ^tBu), 1.35 (s, 9H, ^tBu), 2.90 (s, 1H, Si-*H*), 4.74 (d, *J* = 13.0 Hz, 1H, PhC*H*₂O), 5.09 (d, *J* = 13.0 Hz, 1H, PhC H_2 O), 7.07 (t, J = 7.7 Hz, 1H, H_{para}). 7.21 (t, J = 7.7 Hz, 2H, H_{meta}), 7.46 (d, J = 7.7 Hz, 2H, H_{ortho}); ¹³C-NMR (C₆D₆) δ -4.6, -4.3, -0.6, 0.1, 22.0, 22.4, 22.6, 22.7, 22.9, 23.0, 23.3, 24.7, 30.4 (2C), 30.5, 30.7, 30.9, 31.2 (2C), 31.8, 73.0 (PhCH₂O), 126.7, 127.4, 128.5, 141.0; ²⁹Si-NMR (C₆D₆) δ – 148.9 (Si – H), -7.4 (Si-OCH₂Ph), 15.3, 20.8, 28.6, 32.1; MS (m/ z) 866 (M⁺, 0.2%), 775 (M⁺ –CH₂Ph, 1%), 617 (M⁺ – SiMe^tBu₂-PhCH₃, 3.5%), 91 (PhCH₂, 100%).

3.10. Reaction of 1,2,3,3-tetrakis[di-tertbutyl(methyl)silyl]-1-disilagermirene (3) with acetophenone

Dry acetophenone (20.6 mg, 0.17 mmol) was vacuum transferred to a solution of 3 (110 mg, 0.15 mmol) in dry deuterobenzene (0.7 ml) in NMR tube, and then NMR tube was sealed under vacuum. The reaction progress was monitored by NMR spectroscopy. In 2 h at room temperature the reaction was complete and exclusively one product (cis-adduct) 7 was detected. NMR spectra of *cis*-isomer in the reaction mixture: 1 H-NMR (C₆D₆) δ 0.28 (s, 3H, Me), 0.29 (s, 3H, Me), 0.36 (s, 3H, Me), 0.45 (s, 3H, Me), 1.16 (s, 9H, ^tBu), 1.18 (s, 9H, ^tBu), 1.20 (s, 9H, ^tBu), 1.24 (s, 9H, ^tBu), 1.26 (s, 9H, ^tBu), 1.29 (s, 18H, 2^tBu), 1.34 (s, 9H, ^tBu), 3.44 (s, 1H, Si–H), 5.07 (unresolved doublet, 1H, $C=CH_2$), 5.14 (unresolved doublet, 1H, C=CH₂), 7.03-7.15 (m, 3H, H_{para}+H_{meta}), 7.65 (d, J = 7.6 Hz, 2H, H_{ortho}); ¹³C-NMR (C₆D₆) δ -3.9, -3.6, -1.9, 1.4, 22.25, 22.32, 22.4, 22.66, 22.69,23.0, 23.5, 23.8, 30.2, 30.5, 30.7, 30.8, 31.0, 31.1, 31.3, 32.0, 94.1 (C=CH₂), 126.7, 128.2, 128.5, 138.8, 157.3 $(C=CH_2)$; ²⁹Si-NMR (C₆D₆) δ -145.6 (Si-H), -19.0 (Si-O), 19.2, 24.1, 29.3, 31.5.

cis-Isomer 7 gradually isomerized to a *trans*-isomer 7; in 1 day at room temperature the ratio *cis*-isomer:*trans*isomer = 50:50%, in 2 days at room temperature only *trans*-isomer 7 was detected by NMR spectroscopy. This

trans-isomer was quantitatively isolated by the recrystallization from hexane as pale-yellow crystals. M.p. $179-181 \,^{\circ}\text{C}; \,^{1}\text{H-NMR} \,(\text{C}_{6}\text{D}_{6}) \,\delta \,0.23 \,(\text{s}, 3\text{H}, \text{Me}), \,0.39$ (s, 3H, Me), 0.41 (s, 3H, Me), 0.47 (s, 3H, Me), 1.22 (s, 9H, ^tBu), 1.23 (s, 9H, ^tBu), 1.26 (s, 9H, ^tBu), 1.28 (s, 9H, ^tBu), 1.29 (s, 9H, ^tBu), 1.30 (s, 9H, ^tBu), 1.31 (s, 18H, 2^{t} Bu), 3.01 (s, 1H, Si–H), 5.07 (d, J = 1.6 Hz, 1H, C=C H_2), 5.14 (d, J = 1.6 Hz, 1H, C=C H_2), 7.06 (t, J = 7.2 Hz, 1H, H_{para}), 7.19 (t, J = 7.2 Hz, 2H, H_{meta}), 7.69 (d, J = 7.2 Hz, 2H, H_{ortho}); ¹³C-NMR (C₆D₆) δ -4.24, -4.21, -0.2, 0.1, 22.3 (2C), 22.5 (2C), 22.7, 23.1, 23.5, 25.0, 30.4, 30.5, 30.6, 30.7, 31.1, 31.3, 31.5, 32.0, 94.1 $(C=CH_2)$, 126.8, 128.3, 128.6, 138.5, 159.3 $(C=CH_2)$; ²⁹Si-NMR (C₆D₆) δ –142.2 (Si–H), –17.6 (Si–O), 17.2, 23.0, 28.8, 32.4; MS (m/z) 878 $(M^+, 11\%)$, 758 (M⁺ -CH₃COPh, 5%). Anal. Found: C, 60.50; H, 10.45. Calc. for C₄₄H₉₂GeOSi₆: C, 60.17; H, 10.56%.

3.11. Crystal structure analyses of the compounds 3, 5, and trans-7

The single crystals of compounds 3 and trans-7 for Xray diffraction study were grown from the saturated hexane solutions, single crystals of compound 5 were grown from the saturated benzene solution. Diffraction data were collected at 150 K for 3, 120 K for 5 and trans-7 on a Mac Science DIP2030 Image Plate Diffractometer with a rotating anode (50 kV, 90 mA) employing graphite-monochromatized Mo- K_{α} radiation ($\lambda = 0.71070$ Å). The structures were solved by the direct method, using SIR-92 program [22], and refined by the full-matrix least-squares method by SHELXL-97 program [23]. The crystal data and experimental parameters for the X-ray analysis of 3, 5, and trans-7 are listed in Table 1. Crystallographic data of 3 have been deposited with the American Chemical Society (see Ref. [7]). This material is available free of charge via the Internet at http://www.pubs.acs.org. Crystallographic data of trans-7 have been deposited with the Cambridge Crystallographic Data Centre. CCDC No. 170581. Copies of this information may be obtained free of charge from the Director, CCDC, 12 Union Road, Cambridge CB2 1EZ, UK (Fax: +44-1223-336033; email: deposit@ccdc.cam.ac.uk).

Acknowledgements

This work was supported by a Grant-in-Aid for Scientific Research (Nos. 13029015, 13440185, 14078204) from the Ministry of Education, Culture, Sports, Science and Technology of Japan and TARA (Tsukuba Advanced Research Alliance) fund, and COE (Center of Excellence) program.

Table 1

Crystallographic data and experimental parameters for the crystal structure analysis of 3,5, and trans-7

	3	5	trans-7
Empirical formula	C ₃₆ H ₈₄ GeSi ₆	C ₃₇ H ₈₇ GeISi ₆	C44H92GeOSi6
Formula mass $(g mol^{-1})$	758.16	987.20	878.31
Collection temperature (K)	150	120	120
$\lambda (Mo-K_{\alpha}) (\dot{A})$	0.71070	0.71070	0.71070
Crystal system	Monoclinic	Monoclinic	Monoclinic
Space group	$P2_1/c$	$P2_1/n$	$P2_1/c$
Unit cell parameters			
a (Å)	24.131(1)	13.0950(4)	11.0980(2)
b (Å)	11.6630(6)	20.2620(6)	20.9340(5)
c (Å)	17.760(1)	20.1520(3)	22.8640(6)
α (°)	90	90	90
β (°)	110.362(4)	93.974(2)	96.8960(10)
γ (°)	90	90	90
$V(\text{\AA}^3)$	4686.0(5)	5334.1(2)	5273.5(2)
Ζ	4	4	4
$D_{\rm calc} ({\rm g}{\rm cm}^{-3})$	1.075	1.218	1.106
$\mu (\mathrm{mm}^{-1})$	0.829	1.314	0.746
$F(0\ 0\ 0)$	1664	2080	1920
Crystal dimensions (mm)	0.4 imes 0.3 imes 0.3	0.2 imes 0.2 imes 0.2	0.4 imes 0.3 imes 0.3
θ Range (°)	2.29 - 27.93	2.06 - 27.89	2.09-27.93
Index ranges	$0 \le h \le 31$	$0 \le h \le 17$	$0 \le h \le 13$
	$0 \le k \le 15$	$0 \le k \le 26$	$0 \le k \le 27$
	$-23 \le l \le 21$	$-26 \le l \le 26$	$-30 \le l \le 29$
Collected reflections	46 096	53 594	52 312
Independent reflections	10779	12 709	11951
R _{int}	0.101	0.0520	0.0290
Reflections used	10779	12 709	11951
Parameters	389	467	471
S ^a	1.044	1.068	1.028
Weight parameters <i>a</i> / <i>b</i> ^b	0.0907/4.6977	0.0860/25.1640	0.0547/2.7170
$R_1^{c}[I > 2\sigma(I)]$	0.0589	0.0630	0.0348
wR_2^{d} (all data)	0.1691	0.1763	0.0953
Maximum/minimum residual electron density (e Å ^{-3})	1.278 / -0.987	2.121/-2.359	0.405 / - 0.794

^a $S = \{\Sigma[w(F_o^2 - F_c^2)^2]/(n-p)\}^{0.5}, n, \text{ no. of reflections; } p, \text{ no. of parameters.}\}$

^b
$$w = 1/[\sigma^2(F_o^2) + (aP)^2 + bP]$$
, with $P = (F_o^2 + 2F_o^2)/3$.

^c
$$R_1 = \Sigma ||F_0| - |F_c|| / \Sigma |F_0|.$$

^d $wR_2 = \{\Sigma[w(F_o^2 - F_c^2)^2] / \Sigma[w(F_o^2)^2] \}^{0.5}.$

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